

IN THE CLAIMS:

Please amend Claim 1 and add new Claims 15-19 as follows.

1. (Currently Amended) An electrophoretic display device, comprising:
a substrate,
a sealing plate;
a partition wall disposed between the substrate and the sealing plate,
a liquid layer, disposed in a container including the substrate and the partition wall,
comprising electrophoretic particles and a dispersion medium,
a first electrode formed at a position apart from the partition wall on the substrate,
a second electrode formed along the partition wall,
means for applying a voltage between the first electrode and the second electrode, and
a resistance layer electrically connecting the first electrode and the second electrode is
~~formed, the resistance layer formed at a surface of the substrate defining part of the container and~~
continuously arranged between a surface of a liquid layer side of the first electrode and a surface
of a liquid layer side of the second electrode.

2. (Cancelled)

3. (Previously Presented) A device according to claim 1, wherein the resistance layer is formed to cover the partition wall.

4. (Previously Presented) A device according to claim 1, wherein the resistance layer has a resistance value smaller than a resistance value of the liquid layer.
5. (Original) A device according to claim 1, wherein the resistance layer is formed of a transparent material, and a light reflection layer is disposed opposite to the liquid layer through the resistance layer.
6. (Original) A device according to claim 5, wherein between the resistance layer and the light reflection layer, a coloring layer formed of an insulating material is disposed.
7. (Original) A device according to claim 1, wherein the first electrode is extendedly formed opposite to the liquid layer through the resistance layer and an insulating layer.
8. to 14. (Cancelled)
15. (New) A device according to claim 1, wherein the resistance layer comprises an organic compound film of polysilane, polysiloxane, polyacetylene, composites thereof, or copolymers thereof.
16. (New) A device according to claim 1, wherein the resistance layer comprises an indium-tin-oxide film.

17. (New) A device according to claim 1, wherein the resistance layer comprises semiconductor film.

18. (New) A device according to claim 1, wherein the resistance layer comprises electroconductive resin film including metal powder in epoxy resin, carbon particles in epoxy resin, metal powder in polypropylene, carbon particles in polypropylene.

19. (New) A device according to claim 1, wherein the first electrode is formed of a metal film.